feedback

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databases

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Advanced Search: INSPEC - 1969 to date (INZZ)



Search history:

options

No.	Database	Search term	Info added since	Results	
1	INZZ	planariz\$ OR polish\$ AND capacitor	unrestricted	2886	show titles
2	INZZ	1 AND cmp	unrestricted	589	show titles
3	INZZ	1 AND dram	unrestricted	106	show titles
4	INZZ	1 AND trench ADJ capacitor	unrestricted	8	show titles
5	INZZ	1 AND (via OR hole OR window OR opening)	unrestricted	431	show titles

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whole document	▼ .
Information added since: or: none ▼	search
(YYYYMMDD)	

Select special search terms from the following list(s):

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L	Hits	Search Text	DB	Time stamp
Number				
1	28947	CAPACITOR AND (PLANAR\$ OR POLISH\$) AND	USPAT;	2003/04/10
		(OPENING OR HOLE OR WINDOW OR CONTACT OR	US-PGPUB;	11:28
		VIA)	EPO; JPO;	
			DERWENT;	
			IBM_TDB	
8	5898	(CAPACITOR AND (PLANAR\$ OR POLISH\$) AND	USPAT;	2003/04/10
		(OPENING OR HOLE OR WINDOW OR CONTACT OR	US-PGPUB;	11:29
		VIA)) AND (CMP OR (CHEMICAL ADJ	EPO; JPO;	1
		MECHANICAL))	DERWENT;	
			IBM_TDB	
15	3449	((CAPACITOR AND (PLANAR\$ OR POLISH\$) AND	USPAT;	2003/04/10
		(OPENING OR HOLE OR WINDOW OR CONTACT OR	US-PGPUB;	11:31
		VIA)) AND (CMP OR (CHEMICAL ADJ	EPO; JPO;	
		MECHANICAL))) AND DRAM	DERWENT;	i
			IBM_TDB	
22	19	(((CAPACITOR AND (PLANAR\$ OR POLISH\$) AND	USPAT;	2003/04/10
ľ		(OPENING OR HOLE OR WINDOW OR CONTACT OR	US-PGPUB;	11:35
		VIA)) AND (CMP OR (CHEMICAL ADJ	EPO; JPO;	
		MECHANICAL))) AND DRAM) AND GPY<1992	DERWENT;	
			IBM_TDB	
29	24	(((CAPACITOR AND (PLANAR\$ OR POLISH\$) AND	USPAT;	2003/04/10
		(OPENING OR HOLE OR WINDOW OR CONTACT OR	US-PGPUB;	11:35
		VIA)) AND (CMP OR (CHEMICAL ADJ	EPO; JPO;	
		MECHANICAL))) AND DRAM) AND @PY<1993	DERWENT;	
			IBM_TDB	

Ĺ	Hits	Search Text	DB	Time stamp
Number		·	Ì	
1	591	((438/243) or (438/386)).CCLS.	USPAT;	2003/04/10
			US-PGPUB;	15:34
			EPO; JPO;	
ì			DERWENT;	
		, '	IBM_TDB	
8	1422	(438/692).CCLS.	USPAT;	2003/04/10
			US-PGPUB;	15:27
			EPO; JPO;	
ļ			DERWENT;	
i			IBM TDB	
15	955	(cmp or (chemical adj mechanical	USPAT;	2003/04/10
		polishing)) and (trench adj capacitor)	US-PGPUB;	15:36
İ			EPO; JPO;	
			DERWENT;	
1			IBM TDB	
22	24	((cmp or (chemical adj mechanical	USPAT;	2003/04/10
		polishing)) and (trench adj capacitor))	US-PGPUB;	15:37
ļ	_	and @py<1993	EPO; JPO;	
i			DERWENT;	
			TRM TRE	